## Accelerators: instruments for science and industry

Lenny Rivkin, EPFL & PSI

PAUL SCHERRER INSTITUT

ÉCOLE POLYTECHNIQUE FÉDÉRALE DE LAUSANNE

Swiss Physical Society Annual Meeting, Geneva, August 23, 2017

Straale transformator 15-3-23 (Förste ich hösten 1922) at de blev h Hoot vaking the R = variabil tat ; Konne Inter Le tils: til at Fursti bevist ulu h Straale hangformatoren blev uttauft ungin

## 90 years of RF accelerators

Symposium on 6 September, 2017 at the Technical University Aachen celebrating 1927 PhD thesis of **Rolf Widerøe** 

#### https://90years-rf-accelerators.de/

#### Über ein neues Prinzip zur Herstellung hoher Spannungen

Von der Fakultät für Maschinenwirtschaft der Technischen Hochschule zu Aachen

#### zur Erlangung der Würde eines Doktor-Ingenieurs

genchmigte

#### Dissertation

vorgelegt von

Rolf Wideröe, Oslo

á

Referent: Professor Dr.-Ing. W. Rogowski Korreferent: Professor Dr. L. Finzi

Tag der mundlichen Prüfung: 28. November 1927

## 27 pages

Sonderdruck aus Archiv für Elektrotechnik 1928, Bd. XXI, Heft 4 (Verlag von Julius Springer, Berlin W 9)

#### World of Accelerators



High energy particle physics



## **Draft Schedule Considerations**





FCC Study Status and Plans Michael Benedikt 3<sup>rd</sup> FCC Week, Berlin, 29 May 2017

#### Beam stability studies for the LHC, HL-LHC, HE-LHC and FCC

ÉCOLE POLYTECHNIQUE Fédérale de Lausanne



### 16 Tesla magnet R&D for FCC

### 333 B. Auchmann





#### High field magnets for HEP, medicine and light sources



## ILC

- ILC TDR describes 500 GeV machine
- LCC Physics and Detector Group and JAHEP study: compelling physics case for 250 GeV ILC
- Starting with a 250 GeV Higgs factory + cavity R&D could allow for 40% lower cost than TDR
- The energy of a linear collider
  can be increased
- 250 GeV would be an important stepping stone for future development of the linear collider technology







#### Under study is also klystron based machine for initial stage

Parameter	Unit	380 GeV	3 TeV
Centre-of-mass energy	TeV	0.38	3
Total luminosity	10 <sup>34</sup> cm <sup>-2</sup> s <sup>-1</sup>	1.5	5.9
Luminosity above 99% of vs	10 <sup>34</sup> cm <sup>-2</sup> s <sup>-1</sup>	0.9	2.0
Repetition frequency	Hz	50	50
Number of bunches per train		352	312
Bunch separation	ns	0.5	0.5
Acceleration gradient	MV/m	72	100
Site length	km	11	50



## Intensity Frontier



### PSI Ring Cyclotron in 1973 planned for 100 $\mu A$

590 MeV proton cyclotron was planned for **100 μA** 

Today 2400 µA

Or

1.4 MW beam power





#### High intensity accelerators for research and industry



nEDM

High intensity frontier: essential to have low beam losses

Frequency of operation at certain level of beam losses + reliability increases to over 90 %





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Synchrotron Light Sources

#### Synchrotron Light Sources: about 50 storage ring based



#### Muscles and tracheal network *during* flight



R. Mokso et al., Scientific Reports 5 8727 (2015)

#### Ptychography applications





3D PXCT of unstained brain tissue Shahmoradian *et al*. Submitted



#### Next generation of diffraction limited storage ring based sources

Two orders of magnitude increase in source brightness: needed for the flagship applications like ptychography



#### SwissFEL – a new accelerator based Research Infrastructure

#### 3<sup>rd</sup> gen. synchrotron

fine, slow



#### optical lasers

fast, coarse





# **SwissFEL** fine **and** fast at extreme high intensity





new direct insights into chemical, physical, biological mechanisms governing our daily-life

#### **X-Ray Free Electron Lasers**







Compact Light Source

Electron Beam Injector

RF Gun

and Laser

# Compact light sources based on Compton scattering



# The Problem: EUV Lithography needs mask inspection

- Chip production using Extreme UV radiation (EUV,  $\lambda$ =13,5nm) for lithography to follow Moore's law.
- EUV lithography: Planned for HVM production in 2019
- All reflective optics and mask, plasma source
- Conventional photomask inspection does not work for EUV masks
- Finding the elusive defects on the mask is a big problem





EUV light  $\lambda = 13.5 \text{ nm}$ 

6deg. Incident angle

+LR layer •Absorber

Capping layer

Multi lave

Substrate

EUV

mask

### RESCAN project Lensless EUV mask inspection tool for semiconductor industry

#### **Required is:**

1. Experience in EUV coherent scattering microscopy



2. Fast, sensitive detectors



Jungfrau detector

#### All available at PSI!

3. Know-how in accelerator physics & design



Compact synchrotron

Y. Ekinci, PSI

#### Diffraction limited rings technology: a much brighter compact source



#### Brightness vs photon energy of various sources



#### Brightness vs photon energy of various sources



## Accelerators for medicine

#### X-Ray radiotherapy

#### Varian brothers start at Stanford



# 50,000,000

## patients treated with photons



1947, 2 MeV/m One meter long

#### 250 MeV proton cyclotron (ACCEL / Varian)



## **BRAGG PEAK: SPOT SCANNING**

![](_page_30_Figure_1.jpeg)

#### Hadron therapy: method of choice for pediatric cancers

#### CZECH REPUBLIC RUSSIA SWEDEN CANADA GERMANY CHINA 1368 213 POLAND SOUTH KOREA ENGLAND ITALY JAPAN FRANCE 11,368 11,055 SWITZERLAND SOUTH PARTICLE THERAPY AFRICA PROTON ION

#### PATIENTS TREATED WITH CHARGED PARTICLES, BY COUNTRY

# Gantries for hadron therapy

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HR FREY.

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10

IN FREY.

HR FREY

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#### Gantry for carbon therapy (Heidelberg)

![](_page_33_Picture_1.jpeg)

![](_page_33_Picture_2.jpeg)

![](_page_34_Figure_0.jpeg)

914 C. Calzolaio, S. Sanfilippo **EXPECTED IMPROVEMENTS: NOT much smaller, but:** 

 $\Rightarrow$ Weight:

 $\Rightarrow$  Field size:

 $\Rightarrow$  Energy acceptance

200 tons  $\rightarrow$  50 tons 12 x 20 cm<sup>2</sup>  $\rightarrow$  20 x 20 cm<sup>2</sup> 1.5%  $\rightarrow$  20 %

![](_page_35_Picture_0.jpeg)

#### High field magnets for HEP, medicine and light sources

![](_page_35_Figure_2.jpeg)

Compact accelerators: sources of photons, neutrons, electrons etc.

Compact is relative...

Quest for high gradient acceleration

e.g. compact sources for electron diffraction

![](_page_37_Picture_3.jpeg)

![](_page_37_Picture_4.jpeg)

![](_page_38_Picture_0.jpeg)

![](_page_38_Figure_1.jpeg)

Fig. 1. Schematic diagram of an electron linear accelerator by optical maser.

Shimoda Appl. Opt. **1 (1)**, 33 (1961)

![](_page_39_Picture_0.jpeg)

#### RF Acceleration: scaling with frequency

![](_page_39_Picture_2.jpeg)

![](_page_39_Picture_3.jpeg)

![](_page_39_Picture_4.jpeg)

![](_page_39_Picture_5.jpeg)

![](_page_39_Picture_6.jpeg)

![](_page_40_Picture_0.jpeg)

### Peak gradient as a function of Laser Field

![](_page_40_Picture_2.jpeg)

![](_page_40_Figure_3.jpeg)

Peralta et al., Nature **503**, 91 (2013)

#### Switzerland: host to two world leading accelerator centres

Swiss Accelerator Research and Technology CHART Collaboration supports the future accelerator projects at CERN and the development of accelerator concepts beyond the existing technology for synchrotron light sources and medical applications. An extraordinary grant has been released by SERI as initial funding for these activities.

![](_page_41_Picture_2.jpeg)

#### CHART: Swiss Accelerator Research and Technology

![](_page_42_Picture_1.jpeg)

![](_page_43_Picture_0.jpeg)

![](_page_43_Picture_1.jpeg)

Beam Dynamics and Technologies for Future Colliders, 21 February – 6 March 2018, Zürich

![](_page_43_Figure_3.jpeg)

![](_page_43_Picture_4.jpeg)

# ENGINES OF DISCOVERY

![](_page_44_Picture_1.jpeg)

*"Le vérítable voyage de découverte ne consíste pas à chercher de nouveaux paysages, maís à avoir de nouveaux yeux"* 

Marcel Proust

A Century of Particle Accelerators Andrew Sessler • Edmund Wilson

#### Summary

In the past 90 years accelerators have become an essential tool for research and numerous applications, able to address society's essential needs

Future poses formidable challenges for the accelerator R&D, not the least of them is educating the new generation of specialists

CERN and PSI provide a very strong local advantage in Switzerland, for both academia and industry